00862.022032.

## PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE In re Application of: ) Examiner: J. Berman HIROSHI TSUJI ET AL. Group Art Unit: 2881 Application No.: 09/691,234 Filed: October 19, 2000 HAR -6 2003 TECHNOLOGY CENTER 2 For: ELECTRON BEAM LITHOGRAPHY February 24, 2003 **APPARATUS Commissioner For Patents** Washington, D.C. 20231 AMENDMENT AND

## Sir:

## INTRODUCTORY COMMENTS

Applicants petition to extend the time for response to the Office Action of August 22, 2002 to Saturday, February 22, 2003. A check in the amount of \$930.00 in payment of the extension fee is enclosed. Please charge any additional fee and credit any overpayment to our Deposit Account 06-1205.

PETITION FOR EXTENSION OF TIME

In response to that Office Action, please amend the above-identified

application as follows:

I hereby certify that this correspondence is being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231 on February 24, 2003.

(Date of Deposit)

FRANK A. DeLUCIA ame of Attorney for Applicant) February 24, 2003 Date of Signature

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